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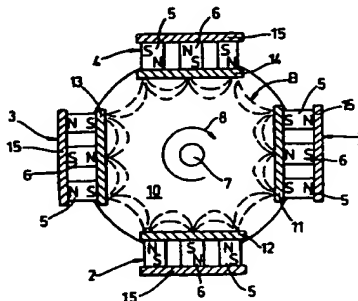
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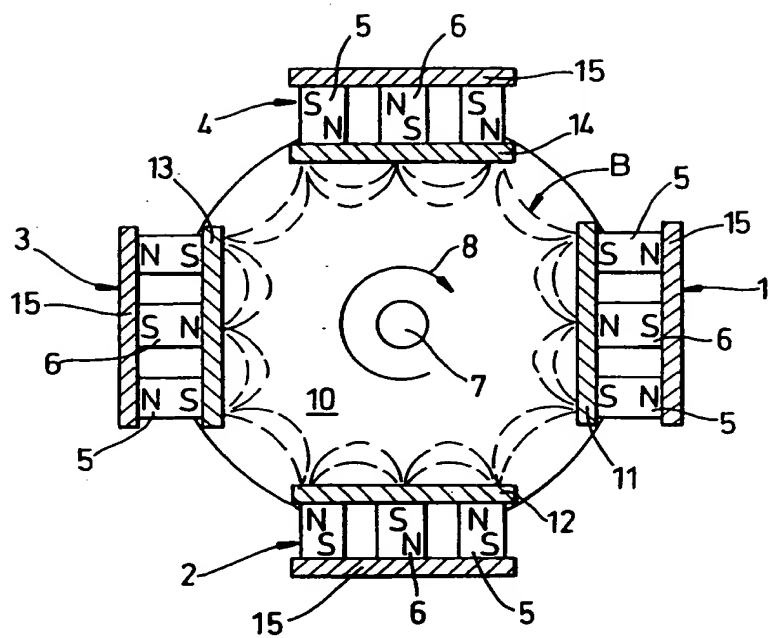
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(54) Abstract Title

Articles bearing carbon coatings

(57) Articles are disclosed which bear a carbon coating layer, wherein carbon-carbon bonding within the coating layer is mostly of the sp² form: wherein the coating has a specific wear rate under wet conditions of less than 10⁻¹⁶ m³/Nm; wherein the coating has an adhesion critical load of at least 70N; wherein the coating has a hardness of at least 1000 VHN; wherein the coating has a coefficient of friction (dry) of not more than 0.1. The coating may be a multi-layer coating containing successive metal-containing and carbon layers. The article may be constituted as a medical prosthesis. Methods are disclosed of forming hard wear resistant carbon coatings by sputter ion plating with at least one carbon target in which an ion current density of for example above 0.5mA/cm² is applied at the substrate to be coated in order to deposit a carbon-containing coating layer and/or which comprise sputter ion plating with at least one carbon target and at least one metal target in order to deposit a carbon coating layer and a metal-containing coating layer. The sputtering may be carried out in the presence of a hydrocarbon or nitrogen. Coating apparatus suitably comprises magnetron sputter ion plating apparatus having at least one metal-donating target and at least one carbon-donating target. Such apparatus may include at least two magnetrons arranged to generate a magnetic field between them with field lines extending from one magnetron to the or an other, and the magnetrons, and field lines extending directly from one magnetron to the or an other, form a barrier which tends to prevent the escape of electrons from within a plasma-containing working space within which the substrate is coated.





CARBON COATINGS, METHOD AND APPARATUS FOR APPLYING THEM, AND ARTICLES BEARING SUCH COATINGS

This invention relates to carbon-containing coatings and to methods of and apparatus for the deposition of such coatings, and to articles bearing such coatings.

Carbon coatings are known *per se*. This invention is particularly
5 concerned with carbon coatings having good hardness and wear resistance. Carbon coatings which have been produced in the past in order to give highly wear resistant surfaces have typically been diamond-like carbon coatings, i.e. carbon coatings which contain a significant amount of material with diamond, sp³, bonding.

10 This invention is based on research carried out with the aim of improving the tribological properties of carbon-containing coatings, and it is an object of this invention to provide a new carbon-containing coating with improved tribological properties and a method and apparatus which may be used to form such a carbon coating.

15 Accordingly, and in its first aspect, the present invention provides an article bearing a carbon-containing coating, wherein carbon-carbon bonding within the coating is mostly of the graphitic sp² form.

20 It is indeed surprising that a carbon-containing coating which is graphitic in structure can in fact have tribological properties, such as greater hardness and wear-resistance, which are much improved over the properties of a carbon-containing coating which is of diamond-like structure.

Such a coating is preferably formed by sputtering, and in its second aspect, the invention provides a method of applying a coating to an article

characterised in that such method comprises using a sputter ion plating system with at least one carbon target in which an ion current density of above $0.5\text{mA}/\text{cm}^2$ is applied at the substrate to be coated in order to deposit a carbon coating layer.

5 This method provides a coating of much improved quality, in particular as regards its tribological properties. The coating layer contains sufficient carbon for there to be carbon-carbon (as opposed to carbide) bonds within it. When deposited in this way, it will be found that those carbon-carbon bonds are predominantly of the sp^2 or graphitic
10 type.

 The invention also provides, in its third aspect, a method of applying a coating to an article characterised in that such method comprises using a sputter ion plating system with at least one carbon target in which an ion current density applied at the substrate to be coated
15 is sufficiently high thereby to deposit a carbon coating layer having improved tribological properties and in which carbon-carbon bonds are predominantly of the graphitic sp^2 form.

 According to a fourth aspect of the invention, there is provided an article bearing a carbon-containing coating, wherein said coating
20 comprises a succession of carbon and metal-containing layers and in which carbon-carbon bonding within the or each carbon layer is mostly of the graphitic sp^2 form, and the invention extends to a method of applying a carbon coating to an article comprising using a sputter ion plating system with at least one carbon target and at least one metal target in
25 order to deposit a carbon coating layer and a metal-containing coating layer.

The use of targets of different compositions, particularly when the substrate is suitably rotated, allows a considerable degree of control of the final coating composition and of different strata within it.

We have found that the presence of a said metal-containing layer
5 can make a significant contribution to the coating properties. In some preferred embodiments of the invention, such a metal-containing layer is an underlayer deposited directly onto the substrate to be overcoated with carbon. Such a metal-containing underlayer is very effective in promoting adhesion between a carbon layer and a substrate.

10 Thus a method according to the invention preferably comprises using a metal target to form a metal-containing underlayer directly onto the substrate which is over-coated with the or a said carbon coating layer.

Such a metal-containing underlayer is preferably deposited to a thickness of between 50 and 200 nm.

15 The underlayer can comprise an initial stratum of metal followed by a second stratum consisting of the metal and carbon produced by co-deposition from metal and carbon targets. This stratum may be harder than the metal stratum and can improve the tribological behaviour of the subsequent carbon coating.

20 Alternatively, or in addition, there may be provided a one or more metal-containing layers each of which is an intermediate layer located between successive carbon layers. This promotes cohesiveness of the coating as a whole. We have found that when a uniform (graphitic) carbon coating is deposited on a substrate, once a certain thickness
25 threshold is exceeded, the coating may have a tendency to spall and that this tendency increases with increasing thickness. We have also found, however, that this tendency is alleviated or even eliminated if thin carbon

layers are interleaved with metal-containing layers. In order to avoid any risk of such spalling, a said carbon-containing layer is preferably formed to a thickness of up to $1\mu\text{m}$.

5 Significant advantages are given by embodiments of the invention in which said coating is built up from a succession of alternating metal-containing and carbon coating layers respectively formed predominantly (that is, more than 50 atoms %) from metal and from carbon. By making use of this feature, the coating as a whole may be built up to any desired thickness, for example up to $10\mu\text{m}$, preferably in the range 1 to $5\mu\text{m}$,
10 and without risk of spalling of the carbon, provided that the carbon layers have thicknesses below $1\mu\text{m}$.

The use of a transition metal, that is a metal in one of Groups 3 to 10 (new IUPAC notation) of the Periodic Table as shown on page 1-15 of *Handbook of Chemistry and Physics*, 77th Edition 1996-1997 (CRC
15 Press), preferably chromium or titanium, is found particularly effective.

A said coating is suitably formed by magnetron sputter ion plating, and most preferably by a technique known as closed field unbalanced magnetron sputter ion plating (CFUBMSIP). Such a technique can be used to produce coatings in accordance with this invention which have
20 quite outstanding properties.. Apparatus for use in such a technique is described later in this specification with reference to the accompanying diagrammatic drawing. Such apparatus is further described in UK Patent No. 2 258 343, and the full contents of that specification are incorporated herein by this reference.

25 Advantageously, at least two magnetrons are arranged to generate a magnetic field between them with field lines extending from one said magnetron to the or an other said magnetron, and said magnetrons, and

field lines extending directly from one said magnetron to the or an other, form a barrier which tends to prevent the escape of electrons from within a plasma-containing working space within which the substrate is coated.

Such a method is particularly apt for achieving a high ion current density at in the region of the substrate being coated. The use of a CFUBMSIP method, in which at least partial closure of the field by such a barrier tends to prevent the escape of electrons from the working space, promotes ionisation in that space, and this in turn acts to promote the intensity of the ion bombardment the substrate will receive during deposition of the coating. As a result, a high ion current density (icd) can be achieved. In preferred embodiments of the invention, such a barrier to electron escape takes the form of a notional tube surrounding the substrate. The ends of such a tubular barrier may be open or closed.

Such a CFUBMSIP method of deposition is the preferred method of deposition although other methods giving high icd can also be used.

When sputter ion plating, the article being coated is preferably held at a bias voltage of from floating voltage to 250V negative. These are inclusive values, and the bias voltage applied may be DC, pulsed DC or RF. Preferably such bias is between 50V and 150V negative, and the best results have been attained when such bias is between 70 and 100 volts negative.

A very simple and preferred way of forming a said coating is to rotate the substrate while it is being coated. This assists in achieving an even coating on the substrate, and also has advantages in the deposition of a plural layer coating.

A particularly convenient way of achieving the optimum proportions of carbon and metal in a multi-layer coating is to use three

carbon-donating targets and one metal-donating target for forming the coating. The substrate may be rotated in a working space between such targets and this is a highly advantageous way of building up a coating from a succession of alternating metal-containing and carbon strata.

5 The rotational speed of the substrate and the rates of deposition of the carbon and metal are suitably so controlled as to yield a period of at least 3 nm in the coating strata. If the period is too small, there is a risk that the carbon and metal will react and combine to form a metal carbide. While metal carbide may be tolerated in any said metal-containing layer,
10 the replacement of carbon-carbon bonds by metal carbide bonds in a said carbon layer would detract from the quite remarkable properties afforded by this invention. It may be noted that it is the carbon layers having graphitic carbon-carbon bonds which provide these tribological properties; while such carbon layers may contain small proportions of metal (and
15 indeed this may be difficult to avoid when using some deposition techniques) the presence of such metal is purely incidental, and the excellent wear-resistance and low friction properties do not depend on the carbon layers containing any metal. The metal-containing layers have a strengthening or adhesion promoting or anti-spalling effect, and they thus
20 allow the coating to be built up to a greater thickness if this is desired. The incorporation of metal layers can also enable the coating to withstand higher loads..

 Preferably, said coating is deposited under an atmosphere containing a noble gas. The use of a noble gas avoids contamination of
25 the deposited coating by compounds of a chemically active gas. It is generally found most convenient to use argon. The argon gas pressure in the sputter system is not critical and can be between about 7×10^{-2} Pa (5×10^{-4} torr) and about 1 Pa (1×10^{-2} torr). Preferably, said coating is

deposited under an argon-containing atmosphere at a pressure of from 0.07 Pa to 0.6 Pa.

While it is desirable to avoid contamination of the coating by compounds of a chemically active gas, the invention does not exclude the possibility of deliberately modifying the coating composition by introducing such a gas into the atmosphere in the sputtering chamber.

Thus for example, the coatings which are formed can be modified by the inclusion of a hydro-carbon gas in the sputtering atmosphere during deposition as is provided in some embodiments of this invention. A feature of such a method may be that a mixture of carbon and metal is sputtered to deposit as a metal-containing layer on the substrate (the article being coated) which layer also contains additional carbon produced by breakdown of any hydrocarbon gas present in the working atmosphere and which deposits directly on the electrically biased substrate. Deposition of a said carbon layer may be by a combination of sputtering from the carbon target and breakdown of the hydrocarbon gas in the plasma.

Also, the coatings as described above can be modified by the addition of nitrogen to the working atmosphere during deposition. This can result in coatings modified by reaction of the nitrogen with the metal to form metal nitrides or with the carbon to form carbon-nitrogen compounds.

According to a further aspect of the invention we provide magnetron sputter ion plating apparatus having at least one metal-donating target and at least one carbon-donating target.

Such magnetron sputter ion plating apparatus preferably comprises at least two magnetrons adapted to generate a magnetic field between them

with field lines extending from one said magnetron to the or an other said magnetron, whereby said magnetrons, and field lines extending directly from one said magnetron to the or an other, form a barrier which tends to prevent the escape of electrons from within a plasma-containing working space within which a substrate may be coated.

Preferably the arrangement is such as to permit the achievement of an ion current density of at least 0.5mA/cm^2 .

The use of carbon and metal targets allows great flexibility in the choice of conditions under which the coating layers are deposited. For example such conditions may be varied to vary the composition of a said metal-containing underlayer as it is deposited, for example so that its composition varies from metal, adjacent the substrate surface, through metal carbide to (graphitic) carbon at the carbon layer.

The invention extends to a coating formed by a method as herein defined and to any article bearing such a coating, and also to:

An article bearing a carbon-containing coating, wherein said coating has a specific wear rate under wet conditions of less than $10^{-16}\text{m}^3/\text{Nm}$, and preferably less than $10^{-17}\text{m}^3/\text{Nm}$;

An article bearing a carbon-containing coating, wherein said coating has an adhesion critical load of at least 70N;

An article bearing a carbon-containing coating, wherein said coating has a hardness of at least 1000 VHN;

An article bearing a carbon-containing coating, wherein said coating has a coefficient of friction (dry) of not more than 0.1;

Any such article wherein said coating is black and/or is electrically conducting.

A said carbon-containing layer should most preferably have a structure with one or more of the following properties:

- 5 an absence of crystallinity detectable by X-ray diffraction or by selected area diffraction in a transmission electron microscope;

a predominant carbon-carbon bonding within the layer of the sp^2 form indicated by Raman spectroscopy;

predominantly graphitic (sp^2) bonding with very small grain size;

- 10 The very high hardness which may be exhibited by the coatings indicates that there must be some cross bonding. The coating structure may contain some C60, and some sp^3 bonding may be present.

We have made various references to the excellent wear resistance properties afforded by coatings formed in accordance with this invention.

- 15 It will be appreciated that different methods of measuring wear resistance may give different results, and accordingly, references in this specification, including its claims, to wear resistance of a given coating are, unless otherwise specified, references to specific wear resistance measured by the following test

20 **SPECIFIC WEAR RESISTANCE TEST.**

A test coating is formed under the same conditions as the given coating but on a substrate which consists of a flat high-speed steel disc. The wear resistance of the test coating is measured in the following way.

- 25 A tungsten carbide pin having a hemispherical head which is uncoated and has a radius of 2.5 mm is rubbed against the test coating on

the flat high speed steel disc. The specific loading on the pin is between 20 and 100 N, and the disc is rotated to give a rubbing speed of 180 mm per minute. (We have found that provided the loading on the pin is between 20 and 100 N, the specific wear rate afforded by this test is substantially independent of the actual loading.) When wet conditions are specified, the rubbing is performed under water unless another liquid is specified.

A taper section (angle less than 5°) through the rubbed surface is examined using an optical microscope at a magnification of 500× to measure of the wear of the coating. This method easily enables the measurement of specific wear rates as low as $10^{-17} \text{ m}^3/\text{Nm}$.

It will be appreciated that other tests are possible, and indeed some other tests are referred to in this specification. It is the test of the immediately preceding paragraphs which is the one which governs the values given in the claims of this specification.

A coating formed in accordance with this invention is useful in providing a hard, low friction, wear resistant surface for use in conditions where components are highly loaded, whether unlubricated or lubricated by oil or an aqueous medium. Examples of components which could usefully be provided with a coating in accordance with this invention abound in the automobile industry. Gear wheels, cam shafts, valves, piston rings, cylinder liners may be mentioned.

Also, the invention is of particular value in the field of medical prostheses, such as such as artificial hip, knee, or shoulder joints and heart valves, and the invention extends to a coated article as herein defined which is constituted as a medical prosthesis or a part thereof.

A problem with medical prostheses is the rubbing together of any co-operating surfaces of their moving parts after they have been implanted in the patient. This causes friction and wear of the rubbing surfaces. It is clearly undesirable to have to perform a surgical operation to replace a prosthesis to remedy a problem caused by a worn surface. In addition to mechanical problems associated with wearing of the prosthesis, there can be biochemical problems associated with debris from the wearing of the surfaces of the prostheses. These two problems are well-known.

This invention enables the provision of a new, hard-wearing, low-friction, prosthesis. In particular embodiments, the invention provides a prosthesis having at least a part coated with a coating which has a specific wear rate of $10^{-16} \text{ m}^3/\text{Nm}$ or lower. Preferably the specific wear rate is $10^{-17} \text{ m}^3/\text{Nm}$ or lower, possibly 10^{-18} or $10^{-19} \text{ m}^3/\text{Nm}$ or lower.

The coating is, of course, a low-friction solid lubricant coating.

The invention enables us to provide a prosthesis having a coating such that, when rubbed against a cobalt-chromium plate also coated with a like coating and rubbed with a load of 40N and a rubbing speed of 3 mm/sec, and rubbed with water, no wear could be quantitatively measured after 1000 metres of rubbing.

Again, wear measurement is by inspection of a taper section (angle less than 5°) through the rubbed surface using an optical microscope at a magnification of $500\times$.

The prosthesis suitably comprises a metal substrate bearing the coating.

The coating is desirably formed to coat any mutually rubbing surfaces of the prosthesis which will move relative to each other in use.

Preferably the prosthesis comprises a chromium or titanium member coated with the coating. More preferably, the prosthesis
5 comprises a cobalt-chromium alloy member, a titanium alloy member or a stainless steel member coated with the coating. The titanium alloy is preferably TiAlV.

According to the most preferred embodiments of the invention, a new type of carbon coating with excellent tribological properties has been
10 developed. The new carbon coating appears to have very little diamond bonding. The improvement in coating has been demonstrated in many friction and wear experiments.

The carbon coating is simply deposited by magnetron sputter ion plating from a carbon target. The use of a method and apparatus as
15 described in our UK Patent No. 2 258 343 (and corresponding European Patent No 0 521 045 and US Patent No 5,556,519) gives particularly good results.

In a typical practical embodiment, a four-target closed field unbalanced magnetron sputter ion plating system such as is illustrated in
20 Figure 5 of UK Patent No. 2 258 343 is used.

An embodiment of the invention will now be described by way of example only, and with reference to the accompanying diagrammatic drawing which shows a plan view of an embodiment of closed field unbalanced magnetron sputter ion plating system.

25 In the drawing, four magnetrons 1, 2, 3, and 4 each have an outer ring magnet 5 and a central core magnet 6. The magnetrons are arranged around a carrier 7 for a substrate which is to be coated. The substrate

carrier 7 is arranged to rotate as indicated by arrow 8 about an axis. It is usually most convenient to arrange for the substrate carrier 7 to rotate about a substantially vertical axis. In the drawing, which illustrates a practical arrangement, the outer magnets 5 of the magnetrons 1 and 3 are of south polarity and their inner core magnets 6 are of north polarity (in their regions which face the substrate carrier 7). The outer magnets 5 of magnetrons 2 and 4 are of north polarity and their cores 6 of south polarity (again, in their regions facing the substrate carrier 7). Thus the magnetic field lines B of magnetrons 1, 2, 3, and 4 form a continuous barrier, trapping electrons which diffuse from the magnetron plasmas, and they at least in part define a working space 10 within which the substrate carrier 7 rotates during the coating process. That barrier may extend over the axial ends of the working space 10 (usually its top and bottom) or not, as desired.

The drawing also shows targets 11, 12, 13, 14 of source material associated with the respective magnetrons 1, 2, 3, and 4. These targets cover the faces of the magnetron poles facing the substrate carrier 7, and the magnetrons each have a soft iron backing plate 15 to complete their internal magnetic circuits.

As will be seen from the drawing, the magnetic field lines B surround the substrate carrier 7 and serve to form a tubular working space 10 within which electrons are trapped. Since the electrons cannot escape the system, except perhaps at its axial ends, they are available to enhance the ionisation associated with the substrate, creating a high ion density.

In use an inert gas such as argon is provided in the chamber of the system and electrons are accelerated in the chamber by a potential difference applied to the magnetron targets 11, 12, 13, 14 to ionize the gas, producing more electrons and argon ions. The argon ions present in the chamber bombard the targets of source material and produce a coating flux of source material. It is suitable for three of the targets to be of

carbon while one is of a transition metal such as chromium or titanium. The argon ions also bombard the substrate. The magnetic field lines B serve to form a continuous barrier to the electrons diffusing from the magnetron discharges and ensure that these electrons are not lost to the system through its sides without performing their useful function of enhancing the glow discharge associated with the negatively electrically biased substrates, increasing the ion current to the substrate.

The magnetrons 1, 2, 3, 4 are provided approximately equi-angularly spaced in a ring with the substrate carrier 7 at its centre. They are carried within a coating chamber (not shown) which may be of cylindrical shape having axial bearings for supporting the substrate carrier 7 at its top and base. A pumping port (not shown) is provided out of line with the four magnetrons, for example in its base.

The magnetic field B forms a continuous ring surrounding the substrate and traps electrons in the ring. Since an even number of magnetron pole assemblies is provided the flux ring can be complete. There is an advantage in providing an even number of magnetrons. Six or eight magnetron pole assemblies are also considered good configurations, but clearly more could be provided if desired, and a system with but two magnetrons could also be used. Adjacent magnetrons would have outer magnet assemblies of opposite polarity, as illustrated.

In a variant embodiment, one opposed pair of magnetrons 1, 3 is made stronger than the other pair, and the polarities of one magnetron of that pair are reversed. The arrangement is such that magnetic field lines connect the outer poles of those magnetrons to form the electron barrier, while the other magnetrons 2, 4 are outside that barrier. They thus play no part in confining electrons, and merely serve to donate additional coating material. Such an arrangement is shown in Figure 8 of GB Patent No. 2 258 343.

In the arrangement shown in the drawing, the plating system is arranged with three carbon-donating targets and one chromium-donating target, and the substrates to be coated are held on a rotating carrier 7 mounted between the targets to promote uniformity of coating and so that
5 a multi-layer coating results.

In order to obtain stress-free coatings we prefer to use a fairly low bias voltage on the substrate to be, and accordingly the substrate is maintained at a bias voltage of 70V negative. The sputtering chamber contains an argon atmosphere at a pressure of about 0.3 Pa (2×10^{-3} torr).
10 Use of the four-target closed field unbalanced magnetron sputter ion plating system ensures an ion current density at the substrate which is in excess of 0.5 mA/cm^2 . At low ion current densities, typically less than 0.5 mA/cm^2 , the coating has been found to have inferior tribological properties.

15 The power applied to the carbon target of the magnetron source is not critical and is limited only in the fact that high powers cause cracking of the target.

A typical deposition sequence which produces coatings with quite exceptional tribological properties is as follows:-

- 20
- i. Ion clean the items to be coated;
 - ii. deposit 0.05 to $0.2 \mu\text{m}$ of metal;
 - iii. co-deposit metal and carbon to produce an underlayer stratum of chromium carbide of between 0.1 and $0.3 \mu\text{m}$ thickness;

- iv. gradually reduce the power on the metal target while rotating the substrate to produce a multi-stratum coating layer consisting of successive carbon and metal-containing strata.

This final coating can be as thick as the particular application demands but is typically between 1 and 5 μ m.

The carbon or carbon/metal multi-layer coatings deposited as described above have been found to have remarkable tribological properties.

Adhesion Critical Load > 70N.

The Vickers hardness of the coating formed under the conditions specified was about 2500 VHN, but this can be varied from 1000 to more than 3000 VHN depending on the exact deposition conditions.

Coefficient of friction less than 0.1.

The specific wear rate for unlubricated (dry) rubbing in normal (humid) atmosphere is surprisingly low at about $2 \times 10^{-17} \text{ m}^3/\text{Nm}$. Under lubricated (wet) rubbing, the wear rate is much lower and it was in fact so low that it was difficult to make an accurate measurement of the wear rate under oil or water lubrication. This implies that such wear rate may be below $10^{-18} \text{ m}^3/\text{Nm}$ and possibly even below $10^{-19} \text{ m}^3/\text{Nm}$.

The coating has the ability to resist wear at very high loads: loads of up to 800 N/mm² can be sustained by carbon layers and up to 3000 N/mm² can be sustained by multi-layer coatings in accordance with the most preferred embodiments of this invention. (Load measured when the coating was deposited on a substrate of high speed steel.) The wear coefficient quoted above for unlubricated rubbing is obtained at specific loads over 1800 N/mm².

It may be noted here that coatings formed in accordance with this invention are not intended for use in a vacuum. We have conducted tests under high vacuum and in a dry nitrogen atmosphere, and we have found that the wear rate in high vacuum or dry atmospheres is higher. This is
5 consistent with a carbon coating layer having a largely graphitic structure.

Little sp^3 bonding, i.e. diamond bonding, has been detected by UV Raman spectroscopy, and Raman spectroscopy indicates that the bonding is largely sp^2 , i.e. graphitic bonding. This is consistent with the fact that the coating is electrically conducting and with the higher wear rate
10 experienced under high vacuum conditions.

The hardness between 1000 and 3000 VHN is exceptional for graphitic carbon. The deposition conditions provided by the CFUBMSIP (or other high iced systems) must produce some form of cross bonding to cause the high hardness.

15 The combination of high hardness and low friction is presumably responsible for the exceptionally low wear rate which has been shown in many tests and which is found to be consistently much lower than other carbon based coatings such as metal-containing, diamond-like carbon coatings, and the load-bearing capacity of our new carbon coatings is also
20 much higher.

The coating methods of the present invention are of particular value in the field of medical prostheses because the resulting coatings have remarkable tribological properties; they are stable in water-based fluids and have very, very, low wear rates when wetted by those fluids. Our
25 tests have shown that the wear rate of the coating under unlubricated (dry) rubbing conditions is very low (specific wear rate about $10^{-17} \text{ m}^3/\text{Nm}$ as mentioned above), but when rubbed under water, the wear rate is so low

as to make quantitative measurement very difficult. These tests were performed at low rubbing speeds, where hydrodynamic effects were impossible, and the low wear rate is truly a property of the coating.

5 We have performed further tests to show that similar good results are obtained when rubbing components coated with the carbon-containing coating when they are immersed in a bovine serum (0.01% NaN₃) which simulates the conditions found in a body implant such as an artificial hip joint. Those tests in bovine serum show that the coated implant showed remarkably little wear.

10 Tests have also shown that the coatings are bio-compatible and no deleterious effects have been detected due to the coating. It is known that carbon fibre implants are biologically acceptable. Carbon, in certain forms, is known to be bioactive (encouraging cell growth on it).

15 Cobalt chromium alloy materials are known to be suitable, and indeed conventional, materials for making prostheses such as artificial hip joints. In one test, a cobalt chromium alloy hemispherically-ended pin of radius 2.5 mm was rubbed against an uncoated cobalt chromium alloy flat plate under bovine serum lubrication in a reciprocating wear test. The specific loading was 400 MPa and the rubbing speed was 180 mm per
20 minute. The specific wear rate was found to be 10^{-14} m³/Nm. This is a reference point for comparing the uncoated cobalt chromium alloy material with a material which is coated in accordance with this invention..

25 We then coated the cobalt chromium flat plate with a carbon coating in accordance with this invention. The coating was a carbon-chromium coating deposited by co-sputtering carbon and chromium as described. An underlayer layer of chromium was deposited before the

multi-stratum carbon-chromium layer. The thickness of the carbon-chromium layer was $3\mu\text{m}$.

Using an uncoated chromium alloy hemispherically-ended pin of radius 2.5 mm and a coated cobalt chromium flat plate and, performing the rubbing under water, according to the test herein specified, the wear rate was extremely low and could not be measured accurately. The specific wear rate in this case was certainly much lower than $10^{-17} \text{ m}^3/\text{Nm}$ (which was the approximate wear rate for an equivalent test performed in air in unlubricated conditions with ambient humidity for a coated substrate). Thus, in comparison with an uncoated interface between two relatively moving/rubbing surfaces the coating has reduced the wear rate by a factor of more than 1000.

When the coating was tested in a pin-on-disc machine using a 5 mm diameter hemispherically-ended tungsten carbide pin rubbing a coated cobalt chromium flat plate under water with a load of 40 Newtons and a rubbing speed of 3 mm per second, no wear could be quantitatively measured after 1000 metres of rubbing. Similar results were achieved performing the test in bovine serum.

Measurement was attempted by optical microscopy of a tapered section of the rubbed surface as described above.

The carbon coating of the implant/prosthesis is biocompatible and is suitable for use in a human body.

The coating is suitable for reducing the wear in a wide range of artificial joints, including hip joints, knee joints, shoulder joints, etc. It is also suitable for reducing wear in less highly-loaded body implants, such as artificial heart valves. The above list is representative, but not limiting.

Typical prostheses used as body implants have surfaces which rub together. The two surfaces are usually be metal surfaces undergoing relative movement.

5 The coating may be deposited on one of the prosthesis surfaces which rub together, or on both of the surfaces. Clearly, the latter will give greater advantages.

10 It is envisaged that we would have a coating on a prosthesis/implant with a thickness of up to $10\mu\text{m}$, preferably $1-5\mu\text{m}$. The thickness depends on the use and the target lifetime of the prosthesis, for example practical thickness of a coating for joints is likely to be $3-4\mu\text{m}$ but for less loaded parts (such as heart valves) it is likely to be less. To achieve this sort of coating the technique used will be as described with adjustment of the deposition time to give the required thickness.

CLAIMS

1. An article bearing a carbon-containing coating, wherein carbon-carbon bonding within the coating is mostly of the graphitic sp² form.
2. An article bearing a carbon-containing coating, wherein said
5 coating comprises a succession of carbon and metal-containing layers and in which carbon-carbon bonding within the or each carbon layer is mostly of the graphitic sp² form.
3. An article bearing a carbon-containing coating, wherein said coating has a specific wear rate under wet conditions of less than
10 $10^{-16} \text{ m}^3/\text{Nm}$, and preferably less than $10^{-17} \text{ m}^3/\text{Nm}$.
4. An article bearing a carbon-containing coating, wherein said coating has an adhesion critical load of at least 70N.
5. An article bearing a carbon-containing coating, wherein said coating has a Vickers hardness of at least 1000 VHN.
- 15 6. An article bearing a carbon-containing coating, wherein said coating has a coefficient of friction (dry) of not more than 0.1.
7. An article having the combination of features of any two or more of claims 1 to 6.
8. An article according to any of claims 1 to 7, wherein said
20 coating is black.
9. An article according to any of claims 1 to 8, wherein said coating is electrically conducting.

10. An article according to any of claims 1 to 9, which is constituted as a medical prosthesis or a part thereof.

11. An article according to any of claims 1 to 10, wherein said coating has a thickness of less than $10\mu\text{m}$ and preferably between 1 and
5 $5\mu\text{m}$.

12. An article according to any of claims 1 to 11 which bears a coating comprising a plurality of carbon and intermediate metal-containing layers having a period of at least 3 nm.

13. An article according to any of claims 1 to 12, wherein said
10 coating includes a metal-containing underlayer.

14. An article according to claim 14, wherein said metal-containing underlayer has a thickness in the range 50 nm to 200 nm.

15. An article according to any of claims 12 to 14, wherein such metal-containing layer contains a transition metal.

16. An article according to claim 15, in which the transition
15 metal is titanium or chromium.

17. A method of applying a coating to an article characterised in that such method comprises using a sputter ion plating system with at least one carbon target in which an ion current density of above
20 $0.5\text{mA}/\text{cm}^2$ is applied at the substrate to be coated in order to deposit a carbon coating layer.

18. A method of applying a coating to an article characterised in that such method comprises using a sputter ion plating system with at least one carbon target in which an ion current density applied at the
25 substrate to be coated is sufficiently high thereby to deposit a carbon

coating layer having improved tribological properties and in which carbon-carbon bonds are predominantly of the graphitic sp² form.

19. A method of applying a carbon coating to an article comprising using a sputter ion plating system with at least one carbon target and at least one metal target in order to deposit a carbon coating layer and a metal-containing coating layer.

20. A method according to any of claims 17 to 19, wherein by using a metal target, a metal-containing underlayer is formed directly onto the substrate, and is over-coated with the or a said carbon coating layer.

21. A method according to claim 20, wherein the metal-containing underlayer is deposited to a thickness of between 50 and 200 nm.

22. A method according to claim 19, 20 or 21, which comprises using a target of a transition metal for depositing such metal-containing layer.

23. A method according to claim 22 in which the transition metal is titanium or chromium.

24. A method according to any of claims 17 to 23, wherein said carbon coating layer is deposited to a thickness of not more than 1 μ m.

25. A method according to any of claims 17 to 24, wherein the substrate is rotated while it is being coated.

26. A method according to claim 25, wherein the coating is formed using three carbon-donating targets and one metal-donating target

27. A method according to either of claims 25 and 26, wherein said coating is built up from a succession of alternating metal-containing and carbon coating layers.

28. A method according to claim 27, wherein the rotational
5 speed of the substrate and the rates of deposition of the carbon and metal are so controlled as to yield a period of at least 3 nm in the coating strata.

29. A method according to any of claims 17 to 28, wherein said coating is formed by magnetron sputter ion plating.

30. A method according to claim 29, wherein at least two
10 magnetrons are arranged to generate a magnetic field between them with field lines extending from one said magnetron to the or an other said magnetron, and wherein said magnetrons, and field lines extending directly from one said magnetron to the or an other, form a barrier which tends to prevent the escape of electrons from within a plasma-containing
15 working space within which the substrate is coated.

31. A method according to any of claims 17 to 30, in which the article to be coated is held at a bias voltage of from floating voltage to 250V negative, preferably at a negative voltage of from 50V to 150V, and more preferably at a negative voltage of from 70V to 100V.

20 32. A method according to any of claims 17 to 31 wherein said coating is deposited under an argon-containing atmosphere at a pressure of from 0.07 Pa to 0.6 Pa.

33. Magnetron sputter ion plating apparatus having at least one metal-donating target and at least one carbon-donating target.

25 34. Magnetron sputter ion plating apparatus according to claim 33, wherein such apparatus comprises at least two magnetrons adapted to

generate a magnetic field between them with field lines extending from one said magnetron to the or an other said magnetron, whereby said magnetrons, and field lines extending directly from one said magnetron to the or an other, form a barrier which tends to prevent the escape of
5 electrons from within a plasma-containing working space within which the substrate may be coated.

35. An article bearing a carbon-containing coating substantially as described herein.

36. A method of depositing carbon-containing coatings
10 substantially as described herein.

37. A magnetron sputter ion plating apparatus substantially as described herein.



Application No: GB 9826346.0 Examiner: Pete Beddoe
Claims searched: 1, in part 7-16, 17, 18, in Date of search: 10 February 1999
part 30-32, in part 35 & in
part 36

Patents Act 1977
Search Report under Section 17

Databases searched:

UK Patent Office collections, including GB, EP, WO & US patent specifications, in:
UK CI (Ed.Q): C7F (FCAS, FCAV, FCSX, FCVX, FPCX, FPD, FPEX)
Int CI (Ed.6): C23C 14/06
Other: Online: WPI

Documents considered to be relevant:

Category	Identity of document and relevant passage		Relevant to claims
X,P	GB 2325473 A	(HOUSTON) 25 November 1998 see esp claim 1 & exs	1 at least
X	GB 2303380 A	(TEER) see esp p26 lines 24-29 & p28 lines 1-3	1,17,18 at least
X	EP 0724023 A1	(FRAUNHOFER) see es exs	1 at least
X	EP 0724022 A1	(IBM) see esp exs	1 at least
X	EP 0579983 A1)SUMITOMO) see esp exs	1 at least
X	EP 0561641 A1	(KOMAG) see esp col7 line 41 - col8 line 39 & fig 1	1 at least
X	EP 0244874 A2	(KABUSHIKI) see esp claim 1 & exs	1 at least
X	US 5370684	(SORIN) see esp col5 line 59 - col6 line 20	1 at least
X	US 5202156	(CANON) see esp embodiments	1 at least
X	US 4795656	(MIZOGUCHI) see esp exs	1 at least

X	Document indicating lack of novelty or inventive step	A	Document indicating technological background and/or state of the art.
Y	Document indicating lack of inventive step if combined with one or more other documents of same category.	P	Document published on or after the declared priority date but before the filing date of this invention.
&	Member of the same patent family	E	Patent document published on or after, but with priority date earlier than, the filing date of this application.



Application No: GB 9826346.0

Examiner:

Pete Beddoe

Claims searched:

1, in part 7-16, 17, 18, in
part 30-32, in part 35 & in
part 36

Date of search:

10 February 1999

Category	Identity of document and relevant passage	Relevant to claims
X	US 4725345 (KABUSHIKI) see esp claims 1 & 2	1 at least
X	US 4597844 (KABUSHIKI) see esp exs	1 at least
X	US 4524106 (ENERGY) see esp exs	1 at least
X	WPI Accession no 92-147406/18 & JP 4089212 A (CANON) see abstract	1 at least
X	WPI Accession no 90-129882/17 & JP 2080558 A (NIPPON) see abstract	1 at least
X	WPI Accession no 89-162159/22 & JP 1105326 A (MATSUSHITA) see abstract	1 at least

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than, the filing date of this application.

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